Divisional of Applic. No.

Attorney Docket No.:

FORM PTO-1449 (SUBSTITUTE)

GR 97 P 1861 09/110.052 U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE Applicant Volker Weinrich et al. INFORMATION DISCLOSURE Group Art Unit Filing Date of Divisional STATEMENT BY APPLICANT 2815 1746 August 24, 2000 (37 CFR 1.98(b)) SUB FILING **EXAMINER** PATENTEE CLASS **CLASS** DATE DATE PATENT NO. INITIALS Yuito et al. 07/88 4,760,481 Α -SA 5,057,455 10/91 Foo et al. В 06/92 Douglas C 5,122,225 04/93 Kobeda et al. 5,208,170 D 08/94 Prall et al. E 5,341,016 F 5,350,705 09/94 Brassington et al. Yokoyama et al. 05/96 G 5,515,984 Nulty 10/96 Η 5,562,801 12/96 Summerfelt I 5,585,300 FOREIGN PATENT DOCUMENT TRANSL. SUB CLASS YES | NO COUNTRY CLASS DATE DOCUMENT NO. J K L M N OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.) Patent Abstracts of Japan No. 1-232729 A (Sakota), dated September 18, 1989. $\leq \Delta$ "Etching of TiN local Interconnects Using HBr in a Triode Reactor with Magnetic Confinement" (Zwicker et al.), Proceedings of the International SA Society for Optical Engineering, Vol. 1803, 1992, pp. 97-106. DATE CONSIDERED **EXAMINER** Shamim 3/14/02 EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

FORM PTO-144		STITUTE) OF COMMERCE		Attorney Docket No.: Divisional of Applic. No. GR 97 P 1861 09/110,052								
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SA	Α	5,621,606	04/97	Hwang								
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5A		"Reactive Ion Etching Mechanism of Plasma Enhanced Chemically Vapor Deposited Aluminum Oxide Film in CF ₄ /O ₂ Plasma" (Kim et al.), J. Applied										
5A		Physics, Vol. 78, No. 3, August 1995, pp. 2045-49. "Local Plasma Oxidation and Reactive Ion Etching of Metal Films for Ultrafine Line Pattern Inversion and Transfer" (Nulman et al.), J. Vacuum Science Technology, Vol. B1, OctDec. 1983, pp. 1033-36.										
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5A		"WSi ₂ /Polysilicon Gate Etching Using TiN Hard Mask in Conjunction with Photoresist" (Tabara), J. Applied Physics, Vol. 36, 1997, pp. 2508-13.								
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